Band gap energy determination by photoacoustic spectroscopy under continuous light excitation

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(Received 1 September 2006; accepted 19 October 2006; published online 7 December 2006)

In this work the authors used the photoacoustic spectroscopy under continuous light excitation to determine the optical band gap of semiconductors. The experiments were performed in lead iodide PbI$_2$ and hexagonal silicon carbide 4H-SiC samples. The nonradiative relaxation processes are discussed in terms of the generated signal. A mechanism to describe the signal increase/decrease under the continuous excitation is presented. The results showed that the method was useful to locate the band gap directly from the optical absorption spectra. © 2006 American Institute of Physics. [DOI: 10.1063/1.2402239]

Photoacoustic Spectroscopy (PAS) has been extensively used to determine the optical properties of semiconductor materials via energy transfer processes that result in heat generation. PAS and most of the photothermal methods can provide information regarding the carrier transport properties and the absorption bands of the sample. In this case, an excess of photoinjected carriers with energy $h\nu>\text{E}_g$ in the conduction band is created, followed by electron-phonon collision deexcitation that occurs in the picoseconds scale. Then, the carriers give off the excess of energy to the lattice, they diffuse through the sample and reestablish equilibrium by recombination with the holes in the valence band.

One particular characteristic of the PAS is the fact that the mechanisms responsible for the generation of the photoacoustic signal can be significantly modified depending on whether the measurements are performed with photon energy above or below the band gap. Another important aspect of the technique is that the effective thermal thickness of the sample that contributes to the PS is defined by the thermal diffusion length ($\mu$), the light penetration depth ($l(0)\approx 1/\beta(l)$), with $\beta$ as the optical absorption coefficient and $\lambda$ the light wavelength, and the nonradiative relaxation time ($\tau$), which is a time constant directly related to the phase of the PS. Then, the evaluation of the mentioned parameters allows the use of the technique to perform depth profile analysis and energy transfer processes. In the case of semiconductors, bulk and surface absorptions, below and above the band gap, respectively, can be discriminated with this method.

One of the most important parameter for the electronic and optoelectronic areas 1-12 is the energy band gap of semiconductors. Usually $\text{E}_g$ value is adopted as the absorption edge obtained from a linear fitting in the plot of the square of the wave function of the absorption coefficient 13 versus the photon energy for direct band gap, or the plot of the square root of the product between the absorption coefficient and the phonon energy versus the photon energy 14 for indirect band gap. However, this procedure is not always precise, since the absolute value of $\beta(l)$ in the region where the band gap occurs is not simple to obtain, once it depends on the sample preparation conditions, purity of the used raw materials, and surface optical finishing. Several techniques have been applied to obtain the optical absorption spectra that can be used for the band gap determination, including PAS and more recently photoreflectance. The use of conventional PAS is limited when the nonradiative recombination in the band edge is minimized, while with the photoreflectance techniques usually the fluorescence cannot be separated from the probe light. Therefore, the search for other methods for the precise determination of the semiconductors band gap is desirable.

In this work we analyze the behavior of the PS under continuous laser excitation in two semiconductor samples, the lead iodide PbI$_2$ and the hexagonal silicon carbide 4H-SiC, using an experimental procedure similar to that previously applied to study the oxygen evolution in plant leaves. The influence of the continuous excitation in the mechanisms responsible for the generation of the PS is discussed and adopted to determine the energy of the band gaps directly from the experimental optical absorption spectra.

The testing samples were a bulk single crystal PbI$_2$ and a thin film 4H-SiC crystal. The PbI$_2$ crystal was grown by the Bridgman method with the $c$ axis oriented perpendicularly to the growth axis. The 4H-SiC sample with doping around $7 \times 10^{18}$ cm$^{-3}$ was grown by hot wall chemical vapor deposition.

Photoacoustic spectra were measured between 1.5 and 6.2 eV and normalized with fine carbon black. The experimental setup was a photoacoustic spectrometer with the samples placed in a conventional PAS cell. The light source was a 1000 W Xe-arc lamp and was modulated at a frequency of 20 Hz. The PS signal was detected by a Bruel and Kjaer microphone and processed by a 5210 PAR lock-in amplifier. An Ar$^+$ ion laser tuned at 2.72 and 2.41 eV was used as continuous light source, while at 1.96 and 2.33 eV a He–Ne and a neodymium doped yttrium aluminum garnet...
lasers were used, respectively. First, the photoacoustic spectra were measured while the samples were excited only by the modulated light. Then, the spectra were obtained with simultaneous excitation by the continuous laser light, as can be seen in Fig. 1. In order to better understand the influence of the continuous light over the PS, an additional experiment was performed as follows: the wavelengths of the modulated and continuous light are maintained fixed and the PS is measured as a function of time. In this way, by monitoring the PS when the sample is irradiated with the continuous light, it is possible to determine whether there is an increase or a decrease of the signal.

Figure 2 shows the spectra and the phase for lead iodide with or without excitation by continuous laser light as a function of photon energy. The spectrum of the nonirradiated sample shows an onset of the optical absorption band around 2.3 eV and a broad band around 4.5 eV. The latter is in agreement with previous results for band gap determination using the dielectric function and reflectivity. This peak at 4.5 eV is present in the calculated imaginary part of the dielectric function and the reflectivity. The peak at 4.5 eV is in good agreement with previous results for band gap determination using the first-principles calculations as the nonradiative relaxation time appears to increase.

As mentioned before, the determination of the band gap energy is usually a challenge task. For example, for the PbI$_2$ sample, by assuming the band gap value as the photon energy at the absorption edge, $E_g = 2.35 \pm 0.05$ eV can be identified as the fundamental band gap energy. However, if the optical band gap is evaluated from the plot of the square of the absorption coefficient ($\beta^2$) versus the photon energy, $E_g = 2.28 \pm 0.01$ eV. In this manner, the correct value of the band gap energy is difficult to establish due to the uncertainties in the determination of the absolute value of $\beta(\lambda)$ in the band gap edge. Thus, by excitation with continuous light, as shown in Fig. 2, the generated PS changes for energies higher and lower than the one of the band gap, but they can be considered the same in the region where the nonirradiated and irradiated continuous light spectra cross. The crossing of the spectra, as shown in details in the inset of Fig. 2, can be assumed as the value of the band gap energy, i.e., $E_g = 2.34 \pm 0.01$ eV. This procedure appears to be useful to locate the band gap energy of the sample. It can also be seen in Fig. 2(b) that there is an increase in the phase of the PS under continuous excitation, occurred for all used wavelengths. We will go back to this observation later on in the discussion of the mechanism responsible for the change in the behavior of the PS under continuous excitation as compared to the regular spectrum. In Fig. 3, the same procedure used for PbI$_2$ is applied to analyze the 4H-SiC, a thin film sample. In this case, the energy from the continuous laser is in the band gap region. This fact and the high reflectivity of this sample, which results in very low optical absorption coefficient as compared to PbI$_2$, demanded special care to avoid the contribution of the back scattering. This was done by subtracting the background obtained by measuring the spectrum with the Xe lamp off and the continuous laser light on. The final spectrum shown in Fig. 3 was obtained by averaging three spectra determined in the same condition. By adopting again the crossing region of the spectra for the nonirradiated and irradiated samples as the band gap energy, the achieved value for $E_g$ is $(3.06 \pm 0.01)$ eV. This is the fundamental band gap of this material, originated from the phonon assisted optical transition $\Gamma_n \rightarrow M_n$. It can be noted also that two other semiconductor absorption bands are present at 2.00 eV and around 4.50 eV. The ~4.5 eV absorption is identified from the first-principles calculations as the $M$-point optical direct transition $M_n \rightarrow M_c$. The absorption band around 2.0 eV, which is about 1.1 eV below the conduction band edge, is
important to mention that the higher values of the phase of the generated PS with the continuous light excitation, a light impinged the sample for 4 s. Achtziger and Witthuhn. As noted for the PbI₂ sample, the response regime of the PS when the modulated and continuous effects observed in the spectra are shown in the time response of the PS when the modulated light is at 1.96 eV. In the first 50 s, when only the modulated light is incident on the sample, the PS is low since the absorbed energy is not sufficient for the electrons to reach the conduction band. Then, the PS is generated by the absorption that occurs in the conduction band via thermally assisted interband transition, with the absorption of energy k_BT over the Fermi level allowing some low free carrier concentration, with n<sub>c</sub>~0, but >0. It is important to mention that the higher values of the phase of the PS [Fig. 2(b)] under continuous excitation would imply in a reduction in the PS as a consequence of a higher nonradiative relaxation time. However, as mentioned above, a significant increase in the signal was observed between 50 and 100 s in Fig. 4(a). Our hypothesis to explain this result is that, when continuous light with energy higher than the band gap is incident, the excited electrons are promoted to the conduction band. Then the continuous light induced free carriers absorb the modulated light resulting in an intraband transitions. As a consequence of the higher probability of the modulated light to be absorbed by the excess of free carriers, a higher PS is generated. This mechanism may dominate the signal generation, despite the observed increase in the phase values. This interpretation is also consistent with the results of Fig. 4(b), since although the continuous light at 1.96 eV (lower than the band gap) can be absorbed by the free carriers, it is not chopped and then cannot contribute to the PS.

The decrease of the PS occurs when the modulated light is fixed at 2.72 eV and the continuous light at 2.33 and 1.96 eV, shown in Fig. 4 as curves (c) and (d). In the first 50 s, the modulated light is sufficient for the excitation of the electrons to the conduction band and from there they decay nonradiatively to the valence band generating the PS. When the continuous light is incident, some conduction electrons (free carriers) may absorb energy at the conduction band inducing an intraband transition. In this process, there is an increase in the nonradiative relaxation time [this is confirmed by the higher phase values shown in Fig. 2(b)] and since the PS is inversely proportional to the time of the recombination processes, the generated signal decreases as shown in the time interval between 50 and 100 s in Fig. 4, curves (c) and (d). As the continuous light is off, after 100 s, the original signal is recovered to its original value.

To sum up, in the present work we used the PAS under continuous laser excitation to propose a tool to determine the optical band gap energy of semiconductors. The band gap energy found for PbI₂ and Hf-SiC were 2.34±0.01 eV and 3.06±0.01 eV, respectively. The relaxation processes in the structure of the semiconductor’s energy bands is discussed in terms of the generated PS. The experiments are simple to perform, widening the number of available methods for the study of the energy transfer processes and band gap determination in semiconductors.

The authors acknowledge CAPES, CNPq, REMAN/ CNPq, Swedish Research Council (VR) and the Agency STINT, and Fundação Araucária for the financial support of this work.